

REMARKS

By this amendment, claims 1, 2, 29, 36-39, 49, and 50 have been amended. Claims 1-60 are pending in the application. Applicants reserve the right to pursue the original claims and other claims in this and other applications.

Claims 1-4, 27, 29-33, 35-40, 46, 48-52, and 54 stand rejected under 35 U.S.C. § 102(a) as being anticipated by EP 1,329,432A1 ("Tsunetomo"). This rejection is respectfully traversed.

Claim 1, as amended, recites, *inter alia*, "forming a first opening in the first layer using a first etchant" and "providing a second etchant in the first opening to etch both the substrate and the first layer to form a first mold for a first micro-lens." Tsunetomo does not disclose this feature. Although Tsunetomo discloses the use of "[v]arious etching means," and the use of hydrofluoric acid at various concentrations, Tsunetomo does not disclose "forming a first opening in the first layer using a first etchant" and "providing a second etchant in the first opening to etch both the substrate and the first layer to form a first mold for a first micro-lens" as recited by claim 1. (column 8, lines 50-57; column 10, lines 24-35). That is to say, Tsunetomo only teaches using hydrofluoric acid at one concentration or one etching means in the descriptions and examples disclosed by Tsunetomo. (column 8, lines 50-57; column 10, lines 24-35).

Since Tsunetomo does not disclose all the limitations of claim 1, claim 1 is not anticipated by Tsunetomo. Claim 38 contains limitations similar to those of claim 1 and is allowable at least for the same reasons discussed above with regard to claim 1. Claims 2-4, 27, 29-33, and 35-37 depend from claim 1 and are patentable at least for the reasons mentioned above. Claims 39, 40, 46, 48-52, and 54 depend from claim 38 and are patentable

at least for the reasons mentioned above. Applicant respectfully requests that the rejection be withdrawn and the claims allowed.

Claims 6 and 41 stand rejected under 35 U.S.C. § 103(a) as being unpatentable over Tsunetomo. This rejection is respectfully traversed. Claim 6 depends from claim 1 and claim 41 depends from claim 38 which are allowable over Tsunetomo at least for the reasons discussed above. Applicant respectfully requests that the rejection be withdrawn and the claims allowed.

Claims 34 and 53 stand rejected under 35 U.S.C. § 103(a) as being unpatentable over Tsunetomo in view of U.S. Patent No. 5,708,493 ("Ahsbabs"). This rejection is respectfully traversed. Claims 34 and 53 depend from claim 38, which is allowable over Tsunetomo at least for the reasons discussed above. Furthermore, Ahsbabs does not cure the deficiencies of Tsunetomo. Applicant respectfully requests that the rejection be withdrawn and the claims allowed.

In view of the above, Applicant believes the pending application is in condition for allowance.

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Respectfully submitted,

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